Progress Towards Standardization of Alpha Flux Measurements in Electronic Materials

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Outline

- Overview of current metrology capability relative to industry requirements
- Identify challenges and gaps to close
- Discussion of Standard and problems solved
 - Compensation for different instrument settings
 - Background determination
 - Systematic error detection and correction
- Continuing challenges
 - Universal reference material
 - Improved instrumentation
- Future hurdles to overcome

An upstream materials perspective to SER issues

The Problem



The woods were dark and foreboding, and Alice sensed that sinister eyes were watching her every step. Worst of all, she knew that Nature abhorred a vacuum. Create and maintain an artificially low radiation flux environment where IC components may function reliably without damage!

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IC Materials Overview

- High purity materials, metals, alloys
- Alpha Radiation sources
 - ²¹⁰Pb in Pb/Sn solders
 - U and Th + associated daughters
 - Cosmic
- Alpha Activity Requirements
 - 0.02 α·hr⁻¹·cm⁻² : 1990's
 - 0.002 α·hr⁻¹·cm⁻²: 2001
 - 0.001 α·hr⁻¹·cm⁻²: 2008





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Gas Proportional Counter Summary

- Several OEM's
- Area :1000 4000 cm²
- Geometry: 4π
- Background
 - 2-3 cph optimal, 4-6 nominal
- Lack energy spectroscopy capability
 - Limited ability to identify specific radioisotopes
- Relatively simple, inexpensive instruments

Instrumentation capability lagging

material requirements



Instrument Capability Then and Now



Standard measurement methodology needed

JEDEC 13.4 Subcommittee (Radiation Hardness)

- JC 13.4 Subcommittee sponsored standard in 2004
- Task group convened to identify and address issues
- Solicited input from JEDEC member companies and others willing to contribute
- Establish best measurement practices
- Prescriptive in critical elements, descriptive in informative elements
- Focused on gas proportional systems prevalent in the industry and associated supply chains
- Quantify sources of variation between different laboratories

Contributors

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Task #1: Standardize Instrument Parameters

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- Remove variability between different laboratories due to instrument settings
- Method for setting optimum bias voltage
- Method for setting discriminator
 - Instruments measuring different energy ranges
 - Generally accepted energy range from 1.2-9 MeV
- Method for measuring detector active area
 - Some detectors have "dead zones", so results were biased low
- Sample distance specified

Instrument variation controlled or compensated

Task #2 Background Determination

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- Critical when dealing with low signal/noise
- Background measurement errors propagate to significant error in results
- Method for determination
 - Before/After method
 - Long term average of statistically controlled background
- Contributions of stages or trays
- Prescribed time for counting background relative to precision

Eliminate common discrepancy between laboratories

Task #3 Addressing Systematic Errors

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- Identification
 - Cumulative Density Function
 - F statistic
- Treatment of outliers
- Method for determining count rate stabilization and rejection of initial data
- Specific examples of contamination and associated corrections
 - Contamination from cleaning materials
 - High background
 - High initial readings

Statistically robust measurement process

Task # 4 Miscellaneous Issues

- Detection limit definition and sample calculation
- Secular equilibrium considerations
 - For Pb products, possibility of alpha flux increase
 - Report time interval between processing and measurement
- Uniform format for reporting data
- Annexes for examples
 - Active area determination
 - Application of cumulative density function for identifying systematic errors
 - Alpha emissivity result and error calculation example



Current Status of Standard

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- Joint JC13.4 and JC 14.1 ballot in June 2009
- 6 Yes
- 4 Yes with comments
- 4 No with comments
- 2 No Votes addressed and changed
- 2 Additional votes to be addressed
- Once consensus is reached, final draft goes to JEDEC Board of Directors for final vote

Standard document is a significant step forward, but our work is not done

Continuing Challenges

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- Universal calibration standard material
 - Great in theory
- Practicality?
 - DOT prohibitions to shipping radioactive material
 - Stable activity for years
 - Acceptable emissivity rate
 - Correct energy range
- Such a standard has not been identified yet
- In lieu of a calibration standard, the document requires correlation studies between the two labs before results can be certified as equivalent

When acceptable material is identified, proceed with document revision

Building a Better Mousetrap?

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- Measure increasingly low activity levels in timely manner without loss of precision
- A significant challenge confronting the industry
- Increase signal/background ratio
 - Increase detector area while maintaining background
 - Decrease background
- Future possibilities
 - Large area solid state detectors
 - Pulse shape discrimination techniques
 - Scintillation counting

If you cannot measure, you cannot improve. - Taguchi

Best case scenario: Timely, Precise Analysis

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How low will we go?

Conclusions

- IC roadmaps continue to require lower activity materials
- Industry metrology challenges are non-trivial
- Standard document has been developed to maximize current instrumentation capability
- Industry demands for increased reliability will place a premium on alpha metrology capability
- Metrology must improve significantly to be capable for future requirements
- As instrumentation changes to meet future industry demands, the JEDEC standard is a foundation to build on

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